

FORM PTO-1449	US Dept. of Commerce Patent and Trademark Office	ATTORNEY DOCKET NO.	SERIAL NO.
JUL 02 2004 INFORMATION DISCLOSURE STATEMENT (use several sheets if necessary)		ATMI-668	10/792,038
		APPLICANT	Melissa K. Rath, et al.
		FILING DATE	GROUP
		March 3, 2004	1756

## U.S. PATENT DOCUMENTS

EXAMINER INITIAL		PATENT NUMBER	ISSUE DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
Le	AA	6,276,372	8/21/2001	Lee	134	1.3	
Le	AB	6,242,400	6/5/2001	Lee	510	176	
Le	AC	6,110,881	8/29/2000	Lee	510	175	
Le	AD	5,709,756	1/20/1998	Ward, et al.	134	1.3	
Le	AE	5,419,779	5/30/1995	Ward	134	38	
Le	AF	20020128164	9/12/2002	Hara, Yasushi ; et al.	510	175	11/30/2001
Le	AG	6,329,118	12/11/2001	Hussein, et al.	430	270.1	
Le	AH	10/389,214		Minsek, et al.	430	320	3/14/2003

## FOREIGN PATENT DOCUMENTS

		DOCUMENT NUMBER	PUBLICATION DATE	COUNTRY	CLASS	SUBCLAS S	TRANSLATION YES	NO
							X (abstract only)	

## OTHER DOCUMENTS (Including Author, Title, Journal-Date, Page Number, Etc.)

Le	AI	Ito, "Dissolution Behavior of Chemically Amplified Resist Polymers for 248, 193-and 157 -nm Lithography, IBM J. Res. & Dev., Vol. 45 No. 5, (Sept. 2001)
Le	AJ	M. Hussain, et al. "A Novel Approach to Dual Damascene Patterning", Intel Corporation, Portland Technology Development, Hillsboro, OR

Continue on Page

EXAMINER	DATE CONSIDERED
Hoa Van Le	25 May 2005
EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP § 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to the applicant.	